Piezoelectric effect on anisotropic magnetoresistance in epitaxial CoFe films

Osaka Univ. CSRN¹, Kansai Univ.², Osaka Univ. Grad. Sch. Eng. Sci.³

°Takamasa Usami¹, Hiroyoshi Itoh², Shumpei Fujii³, Takeshi Kanashima³, and Kohei Hamaya^{1,3}

E-mail: usami@ee.es.osaka-u.ac.jp

A recent study reported that the anisotropic magnetoresistance (AMR) effect of single-crystalline CoFe shows a current-orientation dependence due to the electronic band crossing near the Fermi level, meaning an intrinsic mechanism [1]. However, the influence of the electronic band structure was indirectly proved by a comparison of theoretical calculations and experimental data. To verify the intrinsic mechanism, we utilize the piezostrain as a well-established means to tune the electronic band structures [2].

30-nm-thick epitaxial CoFe films were grown on ferroelectric $Pb(Mg_{1/3}Nb_{2/3})O_3$ -PbTiO₃ (PMN-PT) (001) substrates by molecular beam epitaxy. Using the photolithography and Ar ion milling techniques, two different Hall-bar devices for AMR measurements were fabricated along the PMN-PT[100] (CoFe[1-10]) or [110] (CoFe[100]) directions, respectively (see insets of Fig. 1). To modulate the electronic band structure of CoFe via piezoelectric strain, we applied electric fields (*E*) to the PMN-PT[001] direction. At each *E*, angle φ dependence of the resistance was measured under a sufficient magnetic field of ~2 kOe at room temperature. Here φ is the relative angle between the current *J* and the magnetization directions.

Figure 1 shows AMR ratios for the CoFe[1-10] and [100] Hall-bar devices at various *E*. The φ -dependent AMR shows a four-fold symmetry for the [1-10] Hall-bar while a two-fold symmetry is found for the [100] one, being consistent with the previous report in epitaxial CoFe film on MgO(001) [1]. The results are fitted with a phenomenological equation [AMR(φ) = C_0 + $C_2 \cos(2(\varphi + \varphi_2))$ + $C_4 \cos(4(\varphi + \varphi_4))$]. From these analyses, we find that the values of C_i are modulated with hysteric behavior by varying *E*. On the basis of the first-principles calculation, the correlation between the AMR



Fig. 1. φ dependence of AMR ratios for the CoFe[1-10] and [100] Hall-bar devices at various *E* at room temperature. The insets show optical micrographs of the fabricated Hall-bar devices.

changes and electronic band modulation by varying E will be discussed.

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